

ISIG PROCESS IMMERSION SILVER AND IMMERSION GOLD PLATING



Immersion Silver and Semi-Autocatalytic Gold Plating

Umicores' silver and gold plating process (ISIG) provides customers a high performance nickel-free coating which meets most of the common assembly requirements like multiple solderability and bondability with aluminium and gold wire even by existing thermal ageing stress before assembly.

Due to its outstanding film characteristics ISIG deposition is very well suited to withstand the higher requirements of PCB designer concerning fine pattern ability and high frequency signal transfer in combination with complying newest RoHs and WEEE regulations.

ISIG as Final Finish





Advantages

- Nickel free coating
- High conductivity
- Thin and very uniform electroless desposition
- Suitable for (ultra) fine pitch layouts
- Ductile final finish compatible for flex PCB
- Dense and homogenous gold protection layer up to 0.3 μm feasible
- Reliable Pb-free and Sn/Pb soldering
- Excellent Al- and Au-wire bondability

Applications

- Flexboard PCB (FPC)
- Medical technology
- High frequency technology

umicore

Electroplating

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TECHNICAL SPECIFICATIONS IMMERSION SILVER PLATING

Electrolyte characteristics Presa® RGA-14		
Electrolyte type	Displacement process	
Metal content	1.0 (0.8 - 1.2) g/l Ag	
pH value	acidic	
Operating temperature	50 °C	
Deposition rate	approx. 0.2 µm/min	

Coating characteristics		
Coating composition	Fine silver	
Purity	99.9 wt%	
Colour of film	Silver	
Recommended thickness	0.1 - 0.4 µm	

TECHNICAL SPECIFICATIONS IMMERSION (SEMI AUTOCATALYTIC) GOLD PLATING

Electrolyte characteristics Gobright® TWX-40		
Electrolyte type	Semi autocatalytic	
Metal content	1.2 (1.0 - 1.4) g/l Au	
pH value	7.1 (6.9 - 7.4)	
Operating temperature	78 (76 - 84) °C	
Deposition rate	0.12 µm/15 min at 78°C	

Coating characteristics		
Coating composition	Fine gold	
Purity	99.9 wt %	
Colour of film	Yellow	
Recommended thickness	0.05 - 0.2 µm	

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Cross-Section Observation by FIB of ISIG Film



Thin and uniform Au/Ag deposition

BGA Solder Ball Shear Results

(ball size 0.76 mm, 30 mil, SAC solder) ISIG PCB, plated with 0.18 μm Ag and 0.15 μm Au



Aluminium Wire Pull Test Results, AlSi1 25 μm ISIG PCB, plated with 0.18 μm Ag and 0.15 μm Au

100 wire break 80 📕 break at wedge 1 Code [%] 60 break at wedge 2 40 lift-off 1st Bond 20 lift-off 2nd Bond 0 Mean pull forces: > 7.4 g aged 2h/125°C after bonding as plated Standard deviation: < 7.9 % No lift-offs

Gold Wire Pull Test Results, Au Heraeus HD2 25 μm ISIG PCB, plated with 0.18 μm Ag and 0.15 μm Au



YOUR CONTACT

Do you have a specific question or would you like a no-obligation quote calculation? Our specialist will be happy to help you with any technical questions you might have.



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